

Notice of References CitedApplication/Control No.
09/069,668Applicant(s)/Patent Under
Reexamination
AHN ET AL.Examiner
W. David ColemanArt Unit
2823

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U.S. PATENT DOCUMENTS

*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Name	Classification
	A	US-			
	B	US-			
	C	US-			
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FOREIGN PATENT DOCUMENTS

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NON-PATENT DOCUMENTS

*		Include as applicable: Author, Title Date, Publisher, Edition or Volume, Pertinent Pages)
	U	Hori et al., "Novel High Aspect Ratio Aluminum Plug for Logic/DRAM LSIs Using Polysilicon-Aluminum Substitute (PAS), IEEE, IDEM December 1996, pp 14.7.1-14.7.3
	V	
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